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1	U.S. UTILITY Patent Application MR O.I.P.E. PATENT DATE SCANNED TR3 O.A. TU
	APPLICATION NO. CONT/PRIOR CLASS SUBCLASS ART UNIT EXAMINER 09/855972 D 219 3742 Kevin Martin Harry Gillis Dmitri Choutov

Method and apparatus for low energy electron enhanced etching of substrates in an AC or DC plasma environment

TITLE

PTO-2040 12/99

		ISSUING C	LASSI	FICAT	ION				
ORIGINAL		CROSS REFERENCE(S)							
CLASS	SUBCLASS	CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
NTERNATIONAL CLASSIFICATION					 -	-	_		
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. Drwg.	Print Fig.	Total Claims	Print Claim for O.G. OWANCE MAILED		
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may be prohib	ibited by the Un	nited States Code Title 35.	, Sections 122, 181 and 368.		
		ner) (Date)	(Date) ISSUE BAT (Date) may be prohibited by the United States Code Title 35 zed employees and contractors only.		